

### Patent claims

1. Device for ion beam acceleration, comprising:
  - (A) an ion accelerator tank (1) having a central container axis (2) for guiding and accelerating a pulsed ion beam (3) in the container axis (2),
  - (B) an electron beam pulse formation and amplification device (4) having an electron beam axis (5) for microstructuring and amplifying current pulses to supply the device for ion beam acceleration with high-frequency power,**characterised in that**

the electron beam pulse formation and amplification device (4) is arranged with its electron beam axis (5) transverse and offset relative to the container axis (2) and comprises outside the ion accelerator tank (1)

  - (a) an electron gun (6),
  - (b) a high-frequency deflector (7),
  - (c) a d.c. voltage deflector (8),
  - (d) a collector (9) having an opposing field, and
  - (e) a post-deflection accelerator (10)

and comprises inside the ion accelerator tank

  - (f) an output coupler (11) for coupling the power of the electron beam (14) to a consumer (12),
  - (g) a main collector (13) for taking up the residual power of the electron beam (14),

components (a) to (g) of the device being arranged behind one another in the direction of the electron beam (14).
2. Device according to claim 1, **characterised in that** the consumer (12) is the pulsed ion beam (3).
3. Device according to either claim 1 or claim 2, **characterised in that** the output coupler (11) comprises a resonator (15) having in the ion accelerator tank (1) an upper annular gap (16) surrounding the electron beam (14) radially and a lower annular gap (17) surrounding the electron beam (14) radially.

4. Device according to any one of claims 1 to 3, **characterised in that** the output coupler (11) comprises a coupling stage (18) arranged between annular gaps (16, 17), which coupling stage surrounds the electron beam (14) coaxially and is arranged radially offset and transverse to the ion beam (3) inside the ion accelerator tank (1), the coupling stage (18) being fastened to a drift tube mounting (19) of the ion beam (14).
5. Device according to any one of the preceding claims, **characterised in that** the electron beam gun (6) is a Pierce-type electron beam gun.
6. Device according to any one of the preceding claims, **characterised in that** the high-frequency deflector (7) comprises a homogeneous transversely directed alternating field (20).
7. Device according to any one of the preceding claims, **characterised in that** the d.c. voltage deflector (8) comprises a non-homogeneous temporally constant transverse electrical field (19).
8. Device according to any one of the preceding claims, **characterised in that** the output coupler (11) comprises a resonator (15) in its output circuit.
9. Device according to claim 8, **characterised in that** the output circuit (21) comprises a single-column annular cavity (22) as resonator (15).
10. Device for electron beam pulse formation and amplification comprising
  - (a) an electron gun (6),
  - (b) a high-frequency deflector (7),
  - (c) a d.c. voltage deflector (8),
  - (d) a collector (9) having an opposing field,
  - (e) an output coupler (11) for coupling the power of the electron beam (14) to a consumer (12), and
  - (f) a main collector (13) for taking up the residual power of the electron beam (14), components (a) to (g) of the device being arranged behind one another in the direction of the electron beam (14).





23. Method according to claim 22, **characterised in that** the decoupling of the high-frequency energy is effected by way of a coaxial cable end (24) that projects, by way of an antenna (23), into an annular resonator chamber (27) that communicates with the high-frequency energy-rich electron beam (14) by way of an annular gap (25) surrounding the electron beam (14).
24. Method according to claim 22 or claim 23, **characterised in that** the decoupling of the high-frequency energy is achieved by way of a waveguide which projects, by means of a coupling antenna, into an annular resonator chamber (27) that communicates with the high-frequency energy-rich electron beam (14) by way of an annular gap (25) surrounding the electron beam (14).
25. Method according to any one of claims 22 to 24, **characterised in that** the decoupling of the high-frequency energy is effected by way of a waveguide connected to an annular resonator (27) by way of a coupling window, the resonator (15) communicating with the electron beam (14) by way of an annular gap (25) surrounding the electron beam (14).
26. Method according to any one of claims 22 to 25, **characterised in that** an electron beam (14) having high perveance according to the Child-Langmuir equation is produced by an electron beam gun (6) with an electron beam of from 20 A to 60 A, preferably from 30 A to 50 A, at an acceleration voltage ( $U_c$ ) of from 20 kV to 60 kV, preferably from 30 kV to 50 kV.
27. Method according to any one of claims 22 to 26, **characterised in that** the electron beam (14) is stabilised transversely in Brillouin equilibrium by means of a longitudinal magnetic field.



35. Method according to any one of claims 22 to 34, **characterised in that** residual energy of the electrons is deposited in a main collector (13).
36. Method according to any one of claims 22 to 35, **characterised in that** for electronic deflection in the high-frequency deflector (7) for an operating frequency (f) the actuated high-frequency signal consists of a main component at frequency (f/2) and superposition of frequency (5f/2) at an amplitude ratio of 5:1.
37. Device for high-frequency power amplification, especially for supplying a device having a cavity for ion beam acceleration with high-frequency power, comprising:  
a vacuum tank having a central tank axis for producing and accelerating a pulsed electron beam (14) along the tank axis,  
**characterised in that**  
an electron beam pulse formation and amplification device (4) is arranged with its electron beam axis (5) transverse and offset relative to a container axis (2) of an ion accelerator tank (1) and comprises outside the ion accelerator tank (1)  
(a) an electron gun (6),  
(b) a high-frequency deflector (7),  
(c) a d.c. voltage deflector (8),  
(d) a collector (9) having an opposing field, and  
(e) a post-deflection accelerator (10),  
and comprises inside the ion accelerator tank  
(f) a first gap and a second gap for coupling the power of the electron beam (14) to the ion beam (3),  
(g) a main collector (13) for taking up the residual power of the electron beam (14),  
components (a) to (g) of the device being arranged behind one another in the direction of the electron beam (14).
38. Device according to claim 37, **characterised in that** an output circuit comprises an output coupler to feed into a waveguide.

39. Device according to claim 38, **characterised in that** the output circuit is in the form of a single-column cavity.
40. Device according to claim 38, **characterised in that** all of the electron beam energy can be produced in the electron beam gun without post-deflection acceleration.